				Complete if Known		
Sui	bstitute for for	m 1449A&B/I	РТО	Application Number	70/2011/20	
INFORMATION DISCLOSURE				Filing Date		
STATEMENT BY APPLICANT			ANT	First Named Inventor	Yasuhiro Oda	
(use as many sheets as necessary)				Art Unit		
				Examiner Name		
Sheet	1	of	1	Attorney Docket Number		

U.S.PATENT DOCUMENT						
Examiner Initials*	Cite No.¹		Document	Number	Publication Date	Name of Patentee or Applicant
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SC		JP	2005-086135	Α	03-31-2005	NIPPON TELEGR&TELEPH CORP	Abstract
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		OTHER PRIOR ART-NON PATENT LITERATURE DOCUMENTS	
Examiner Initials*	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	Translation ⁶
SC		M.W.Dvorak et al., "300 GHz InP/GaAsSb/InP Double HBTs with High Current Capability and BVceo≥6V", IEEE ELECTRON DEVICE LETTERS, VOL.22, NO.8, August 2001, pp361	
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Examiner Signature /Sara Crane/ Date Consid	dered 11/27/2006
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